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Fe³⁺/Nb⁵⁺ Co-doped rutile–TiO₂ nanocrystalline powders prepared by a combustion process: preparation and characterization and their giant dielectric response

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Fe³⁺/Nb⁵⁺ co-doped TiO₂ (FeNb–TO) nanocrystalline powders were prepared by a combustion process. A pure rutile–TiO₂ phase of powders and sintered ceramics with a dense microstructure was achieved. Both co-dopants were homogeneously dispersed in the ceramic microstructure. The presence of oxygen vacancies was confirmed by Raman and X-ray photoelectron spectroscopy techniques. The low-frequency dielectric permittivity enhanced as co-doping concentration increased. The thermally activated giant-dielectric relaxation of FeNb–TO ceramics was observed. Removing the outer-surface layer had a slight effect on the dielectric properties of FeNb–TO ceramics. Density functional theory (DFT) calculation showed that, in the energy preferable configuration, the 2Fe atoms are located near the oxygen vacancy, forming a triangle-shaped FeV₃Ti defect complex. This defect cluster was far away from the diamond-shaped 2Nb₂Ti defect complex. Thus, the electron-pinned defect-dipoles (EPDD) cannot be formed. The giant-dielectric relaxation process of the FeNb–TO ceramics might be attributed to the interfacial polarization associated with electron hopping between Ti³⁺/Ti⁴⁺ ions inside the grains, rather than due to the surface barrier layer capacitor (SBLC) or EPDD effect.

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1. Introduction

Giant dielectric oxides that can exhibit dielectric permittivity (ϵ') values larger than 10^3 have intensively been investigated because of their potential applications in electronic devices, *e.g.*, multilayer ceramic capacitors.^{1–12} Also, the interesting dielectric characteristics of many oxides have stimulated research activity on giant dielectric materials. To clarify the origin of the giant dielectric characteristics, several models have been represented, *e.g.*, nano-barrier layer capacitor, electron-pinned defect-dipole (EPDD), surface barrier layer capacitor (SBLC), internal barrier layer capacitor (IBLC), and polaronic hopping models, as well as the sample-electrode contact effect.^{1,4,13–17} For the EPDD model, free electrons can be

polarized in the defect clusters, giving rise to a high ϵ' . On the other hand, for the SBLC and IBLC models, the polarization that gives rise to a high ϵ' occurs at the internal interfaces between the semiconducting and insulating parts.

One of the most interesting giant dielectric oxides is a co-doped TiO₂ ceramic system. For example, the In³⁺/Nb⁵⁺ co-doped TiO₂ ceramic can exhibit excellent dielectric properties

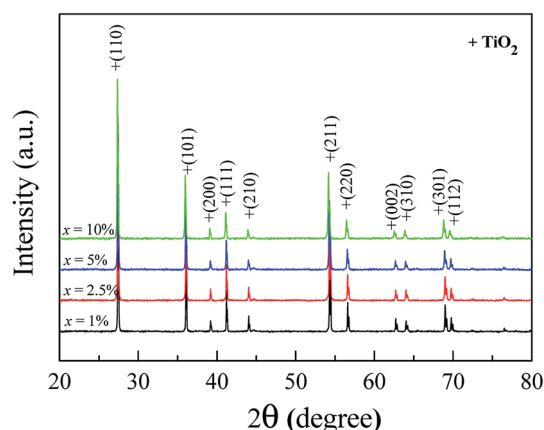


Fig. 1 XRD patterns of the FeNb–TO powders with difference co-doping levels.

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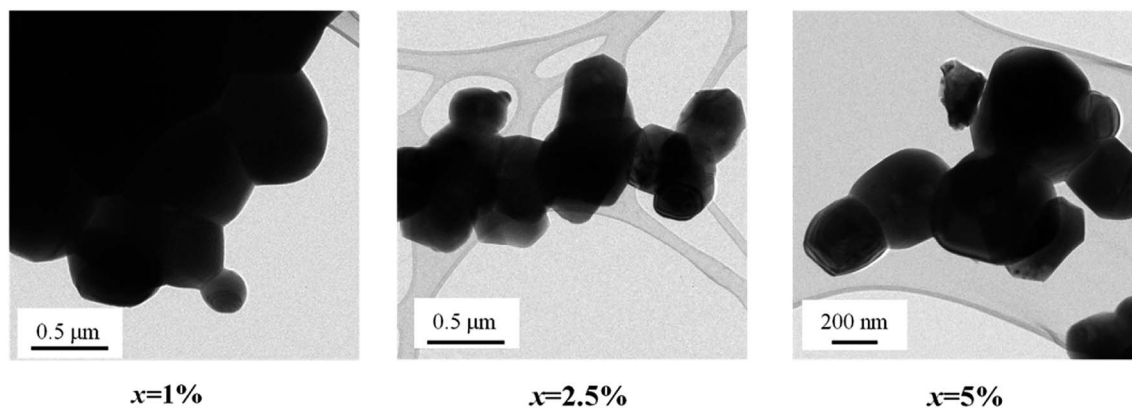


Fig. 2 TEM images of FeNb-TO powders with difference co-doping levels.

with high $\epsilon' \sim 6 \times 10^4$ and low loss tangent ($\tan \delta \approx 0.02$).^{1,18–20} The dielectric properties of this co-doped TiO_2 system ceramics were described as follows: free electrons in the rutile-structure were induced by the substitution of Nb^{5+} ions. These free electrons would be confined in the clusters of defects, which

associated with In^{3+} doping ions.¹ This mechanism was referred to as an EPDD model.¹ Under an applied electric field, free electrons can be polarized in a local structure, leading to an extremely increased ϵ' with a low $\tan \delta$.

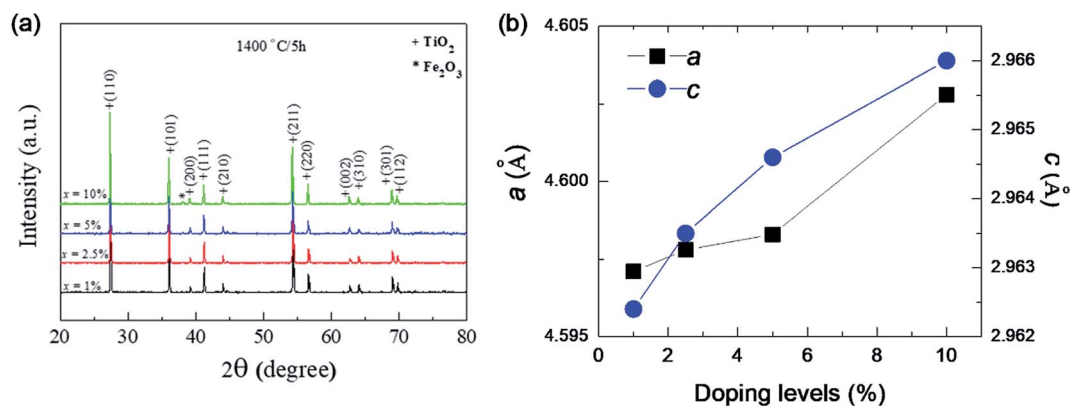


Fig. 3 (a) XRD pattern of the as-sintered FeNb-TO ceramics with difference co-doping levels. (b) Lattice parameters (a and c) for all doping levels.

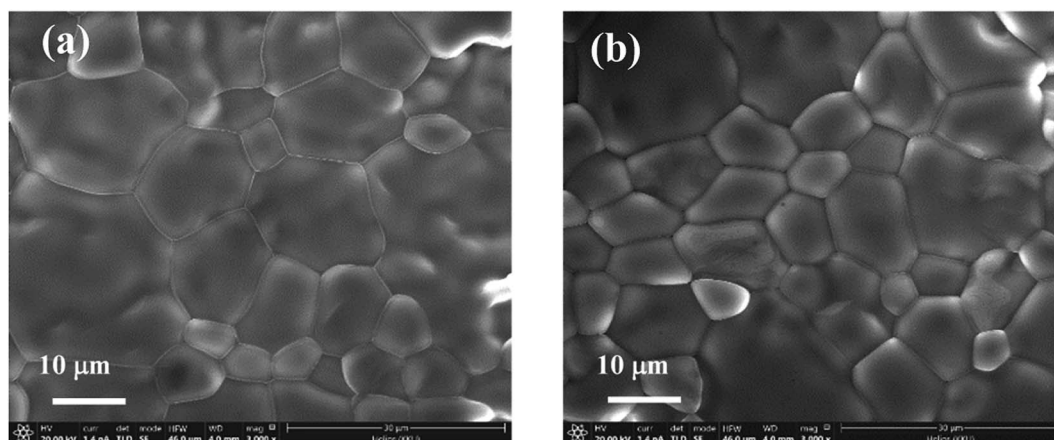


Fig. 4 SEM images of FeNb-TO ceramics with (a) $x = 5\%$ and (b) $x = 10\%$.

Up to now, the giant dielectric properties of several co-doped rutile-TiO₂ systems have been investigated, *e.g.*, Yb³⁺/Nb⁵⁺,²¹ Zr⁴⁺/Nb⁵⁺,¹⁰ Zn²⁺/Nb⁵⁺,²² Al³⁺/Nb⁵⁺,²³ Ga³⁺/Nb⁵⁺,¹³ V³⁺/Ta⁵⁺,²⁴ Sm³⁺/Ta⁵⁺,²⁵ Bi³⁺/Nb⁵⁺,²⁶ Ga³⁺/Sb³⁺,²⁷ and Ga³⁺/Ta⁵⁺.²⁸ Almost systems showed very large ϵ' and low $\tan \delta$. The cause(s) of such an excellent

dielectric response was described using different models.^{1,13,14,18,23,26,28} The EPDD model was proposed and used to reasonably described the giant dielectric properties in many co-doped TiO₂ systems.^{1,25,29,30} According to the micro-contact *I-V* measurements and impedance spectroscopy analysis,^{31,32} it was

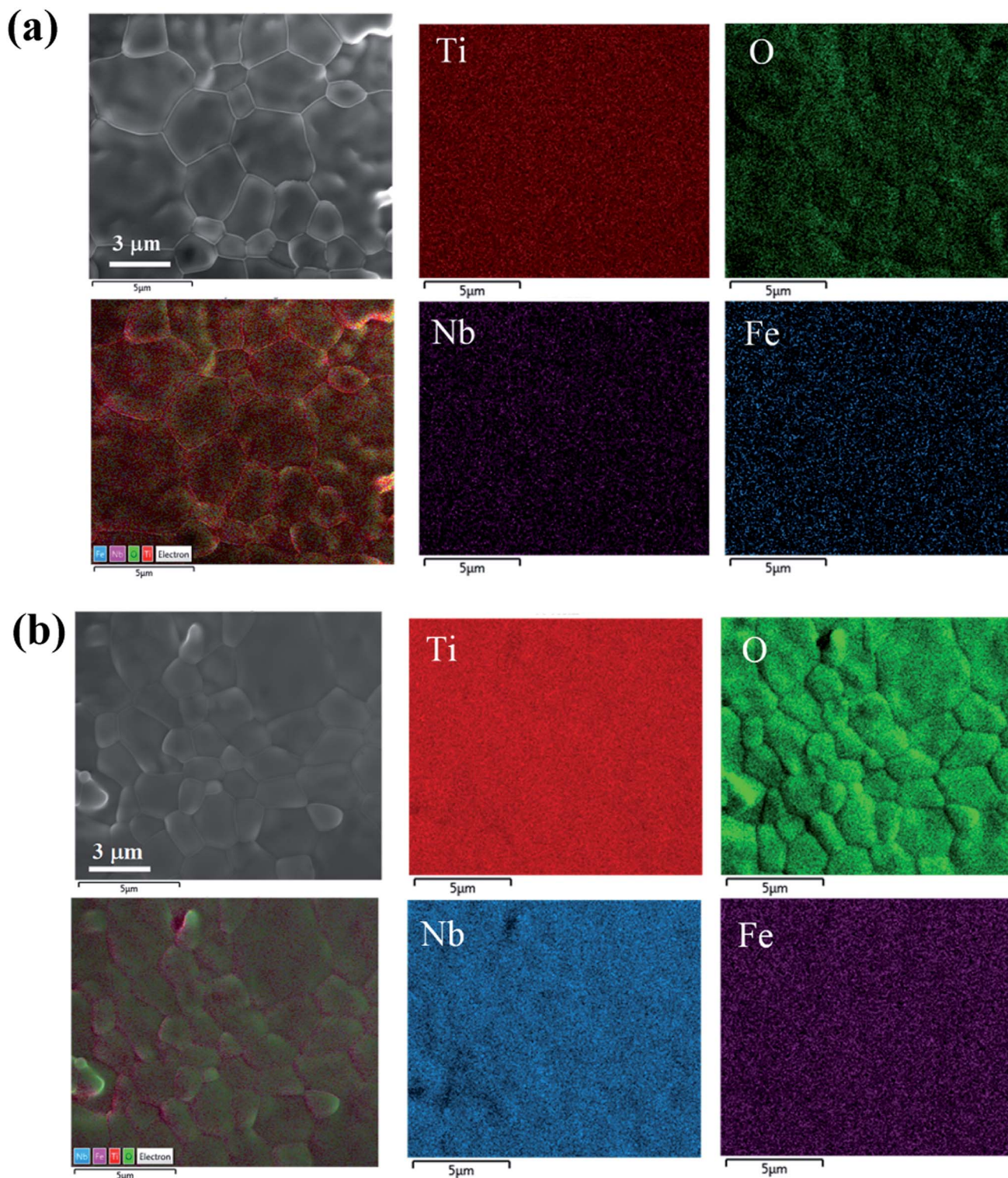


Fig. 5 EDS-mapping images of FeNb-TO ceramics with (a) $x = 5\%$ and (b) $x = 10\%$.



clearly shown that the $\text{In}^{3+}/\text{Nb}^{5+}$ co-doped TiO_2 ceramic was electrical heterogeneous. The resistance of the grain boundary was very large, while the grain was a semiconductor. Hence, the giant dielectric response with a low $\tan \delta$ in the $\text{In}^{3+}/\text{Nb}^{5+}$ co-doped TiO_2 ceramics was attributed to the grain boundary capacitance effect following the IBLC model. Furthermore, it was also demonstrated that the resistive outer surface layer showed a great influence on the excellent dielectric properties,^{14,18,28,33} following the SBLC model. Therefore, the mechanism that gives rise to the enhanced dielectric properties of these ceramic systems was likely unclear now. Both experimental and theoretical studies should be simultaneously performed. Besides these co-doped TiO_2 systems, investigation to seek a new co-doped TiO_2 system is also important for future applications.

According to the previous work,³⁴ it was found that the Fe and Nb dopants can produce Ti^{3+} donor levels and trap states in the TiO_2 structure. The creation of the shallow states had a significant effect on charge carrier transport *via* electron hopping and trapping/de-trapping. Thus, the Fe and Nb doping ions have an essential influence on the electronic conduction by increasing electron density. Thus, it is expected that the dielectric properties of Fe and Nb co-doped TiO_2 ceramics could be obtained since the giant dielectric properties of co-doped TiO_2 ceramics can be contributed by electron hopping.¹³

Therefore, in this current study, the dielectric behavior and theoretical calculation of TiO_2 ceramics co-doped with $\text{Fe}^{3+}/\text{Nb}^{5+}$ ions were done. Experimentally, both powders and sintered ceramics were systematically characterized. The giant dielectric properties at different frequencies and temperatures of this co-doped system were measured to reveal the dielectric relaxation behavior. Theoretically, the density functional theory (DFT) was used to calculate the ground-state structure to know the origin of giant dielectric properties in $\text{Fe}^{3+}/\text{Nb}^{5+}$ co-doped TiO_2 ceramics. The possible cause of the observed giant dielectric response was discussed.

2. Experimental details

$(\text{Fe}_{0.5}\text{Nb}_{0.5})_x\text{Ti}_{1-x}\text{O}_2$ (FeNb-TO) nanoparticles ($x = 1\%$, 2.5% , 5.0% , and 10%) as well as TiO_2 , $\text{Fe}_{0.05}\text{Ti}_{0.95}\text{O}_2$ (Fe-TO), and $\text{Nb}_{0.05}\text{Ti}_{0.95}\text{O}_2$ (Nb-TO) were prepared by a simple sol-gel method. $\text{C}_{16}\text{H}_{28}\text{O}_6\text{Ti}$ (Sigma-Aldrich), $(\text{FeN}_3\text{O}_9) \cdot 9\text{H}_2\text{O}$ (Sigma-Aldrich, >99.99%), NbCl_5 (Sigma-Aldrich, >99.9%), deionized water, and citric acid were used as the starting raw materials. For each co-doping condition (x), the starting raw materials were weighed according to each chemical formula. First, $(\text{FeN}_3\text{O}_9) \cdot 9\text{H}_2\text{O}$ and NbCl_5 were dissolved in an aqueous solution of 5 wt% citric acid with constant stirring at room temperature (RT). Second, a $\text{C}_{16}\text{H}_{28}\text{O}_6\text{Ti}$ solution was added into the solution with stirring at 130°C until a viscous gel was observed. Third, the gel was heated for 1 h at 350°C . Then, the resulting dried precursors for all doping concentrations were calcined in air at 1000°C for 6 h using the heating rate of 5°C min^{-1} . Next, the calcined powders were carefully ground and pressed into pellets with 9.5 mm in diameter and 1.2 mm in thickness. The compressive stress for forming each pellet was

~ 10 MPa. Finally, the pellets were sintered at 1400°C for 5 h in air. The heating and cooling rates were 5°C min^{-1} .

The prepared nanoparticles were characterized by transmission electron microscopy (TEM, FEI/TECNAI G2 20) and X-ray diffraction technique (XRD PANalytical, EMPYREAN). The XRD data were collected in the 2θ range of 20 – 80° by using a step increase of 0.01° per point. The lattice parameters were calculated using a Cohen's least mean square method. Surface morphologies of the sintered ceramics were characterized by a scanning electron microscopy (SEM) (SEC, SNE4500M). An accelerating voltage for electron microscopy was 20 kV. The distribution of all elements in the FeNb-TO ceramics was revealed using a field-emission scanning electron microscopy (FE-SEM, FEI, Hileos Nanolab G3CX). Raman spectra of sintered ceramics were collected with a UV-vis Raman System (NT-MDT Ntegra Spectra) using laser wavelength of 532 nm. The oxidation states in FeNb-TO ceramics were measured by an X-ray photoelectron spectroscopy (XPS), PHI5000 VersaProbe II, ULVAC-PHI, Japan) at the SUT-NANOTEC-SLRI Joint Research Facility, Synchrotron Light Research Institute (SLRI), Thailand. PHI MultiPak XPS software using Gaussian-Lorentzian lines was used to fit the XPS spectra.

Both sides of sintered ceramics were coated by Au sputtering technique. The dielectric parameters were corrected by a KEY-SIGHT E4990A Impedance Analyzer. The measurement was performed in the frequency and temperature ranges of 10^2 to 10^6 Hz and -60 to 200°C using an oscillation voltage of 0.5 V.

The stable configuration of the Fe and Nb co-doped TiO_2 was studied using the density functional theory (DFT) implemented in the Vienna *Ab initio* Simulation Package (VASP). According to the pseudopotential used in this work, the projector augmented wave approach and the Perdew–Burke–Ernzerhof (PBE) form of exchange-correlation functional was chosen. The 600 eV plane-wave energy cutoff and $3 \times 3 \times 3$ k -point samplings with Monkhorst–Pack scheme were successfully tested. To move ion to the lowest energy configuration, the conjugate-gradient algorithm was carried out and the force acting on each ion was calculated by the Hellmann–Feynman theorem.

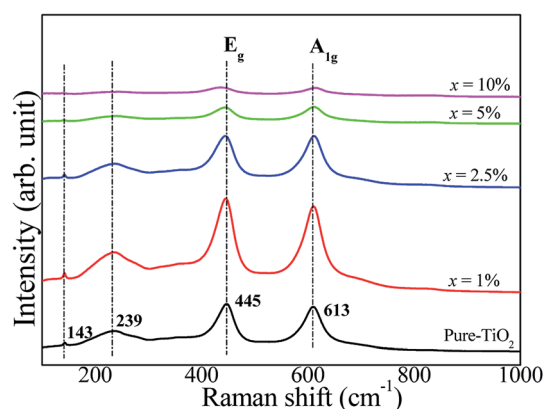


Fig. 6 Raman spectra of rutile- TiO_2 and FeNb-TO ceramics with difference co-doping levels.

3. Results and discussion

Fig. 1 shows the XRD patterns of FeNb-TO powders ($x = 1, 2.5, 5$, and 10%), which were calcined at sintered at 1000 °C for 6 h. All

the XRD patterns show a single phase of rutile-TiO₂. No impurity phase is observed. It was found that lattice parameters (a and c) slightly increased with increasing co-doping concentration. The a values of the 1%, 2.5%, 5%, and 10% co-doped

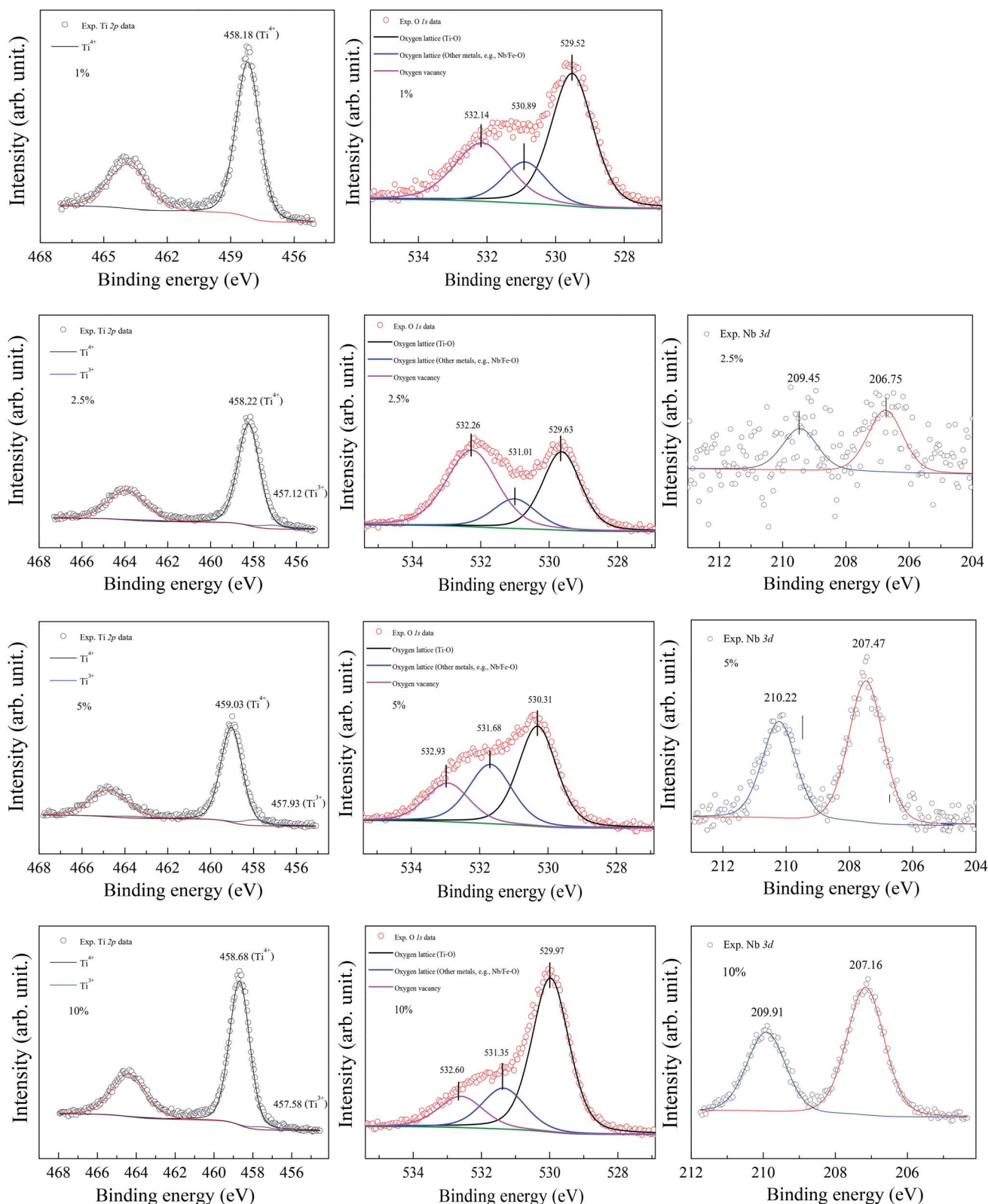


Fig. 7 XPS spectra of Ti 2p, O1s, and Nb 3d for FeNb-TO powders with difference co-doping levels.



powders were 4.5944, 4.5973, 4.6007, and 4.6070 Å, respectively, while the *c* values were 2.9625, 2.9626, 2.9643 and 2.9697 Å, respectively. As revealed in Fig. 2, the agglomeration of the FeNb-TO particles were observed with particle sizes of ~200 nm.

The phase formation and crystal structure of the sintered FeNb-TO ceramics were also studied, as illustrated in Fig. 3(a). All the XRD patterns of the FeNb-TO ceramics sintered at 1400 °C for 5 h also show a main phase of TiO₂ with a rutile structure. The *a* values of the sintered ceramics with *x* = 1, 2.5, 5, and 10% were found to be 4.5971, 4.5978, 4.5983, and 4.6028 Å, respectively. The *c* values were 2.9624, 2.9635, 2.9646, and 2.9660 Å, respectively. As clearly seen in Fig. 3(b), both *a* and *c* values tend to enlarge as the co-doped concentration was increased. This means that Nb and Fe doping ions have substituted into the rutile-TiO₂ structure. It is worth noting that the second phase of Fe₂O₃ was detected in the XRD pattern of the sample with *x* = 10%. This result may be caused by a high co-doping concentration, which was higher than the limit of solid solution in the TiO₂ structure.

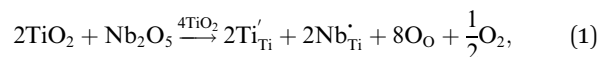
Fig. 4 displays the SEM images of sintered ceramic samples with *x* = 5% and 10%, revealing the morphologies of the ceramic samples. It is clearly seen that the microstructures of all sintered ceramics are fully dense without pores. It is found that the mean grain size tends to decrease with increasing co-doping concentration. This observation is similar to that observed in the Ga³⁺/Ta⁵⁺ co-doped TiO₂.²⁸ This indicates that Fe and Nb doping ions can inhibit the grain growth rate of TiO₂.

Fig. 5(a) and (b) show the SEM-mapping images of the FeNb-TO ceramics with *x* = 5% and 10%, respectively. Both Fe and Nb co-dopants, as well as the major elements, *i.e.*, Ti and O are homogeneously distributed in the microstructure. The cluster of both dopants is not observed in the SEM-mapping images.

The Raman spectra of pure TiO₂ and FeNb-TO ceramics with different co-doping levels were measured, as represented in Fig. 6. The strongest peaks of E_g and A_{1g} modes are detected, which can be indicated to associate with oxygen vacancies and the O-Ti-O bonds, respectively.²³ A_{1g} peak very slightly shifted to higher wavenumbers when *x* > 2.5. E_g peak did not change when *x* ≤ 5%. Unfortunately, the obtained Raman spectrum of the FeNb-TO ceramic with *x* = 10% was not clear to justify the peak positions of these two modes. Nevertheless, the overall results showed that the positions of the peaks of E_g and A_{1g} modes did not significantly change. Usually, TiO_{2-x} is much sensitive to oxygen vacancy concentration. Hence, slightly shifting the position of E_g peak to lower a wave number indicated a slight increase in oxygen vacancies. As shown in Fig. 3, the secondary phase of Fe₂O₃ can be observed in the XRD patterns when *x* ≥ 2.5%. This result indicated that only a small portion of Fe ions can substitute into Ti site in the TiO₂-rutile structure. On the other hand, the shifting of the A_{1g} peak position indicates the influence of Fe and/or Nb on the Ti-O bond, which is owing to the different ionic radii between the host and co-dopant ions.

The XPS spectra of all the sintered FeNb-TO sample are shown in Fig. 7. Unfortunately, the Fe peak in all samples cannot be observed. The Nb peak of the *x* = 1% sample was not also detected in the XPS spectrum. Basically, an oxygen vacancy can be produced in the TiO₂ structure by doping with trivalent

cation (*e.g.*, Fe³⁺) for neutral charge compensation. The XPS spectrum of O 1s profiles is shown in Fig. 7. Using the Gaussian-Lorentzian profile fitting, three peaks were separated. The major peak at 529.92 eV is suggested to the oxygen lattice (Ti-O bond).^{1,35,36} Two peaks located at 531.34 and 532.68 eV are indicated to associated oxygen-cation bonds (*e.g.*, Fe-O and Nb-O bonds) and oxygen vacancies, respectively.^{1,26,35,36} The presence of oxygen vacancies in FeNb-TO ceramics is confirmed. Also, the binding energies of 3d_{3/2} and 3d_{5/2} of Nb 3d electrons are detected at 209.71 and 206.99 eV, respectively. The splitting of the spin-orbit of about 2.72 eV indicates the existence of Nb⁵⁺.¹ Conduction electrons in TiO₂ structure are existed by substitution of Nb⁵⁺, following the equations:



As demonstrated in Fig. 7, a small amount of Ti³⁺ is confirmed to exist in FeNb-TO ceramics.

Fig. 8 depicts the frequency dependence of ε' at RT of FeNb-TO ceramics at RT. Considering in a low-frequency range, ε' increases with increasing co-doping concentration, whereas, ε' slightly enhanced in frequencies higher than 10⁴ Hz. tan δ peaks in a low-frequency range were observed (not shown). The overall dielectric behavior is likely to be the dielectric relaxation behavior. A slight change in ε' in a high-frequency range indicates that Nb⁵⁺ and Fe³⁺ co-doping ions have a slight influence on the ionic polarization. Note that, in the high-frequency region, the ε' values of all FeNb-TO ceramics are closed to the ε' value of pure-rutile TiO₂ ceramics. In contrast, the co-dopants have a remarkable effect on the dielectric response in a low-frequency region, which is usually caused by the interfacial polarization at the internal insulating layer that is contacting a semiconducting region. It is important to note that ε' of FeNb-TO ceramics was lower than that of other co-doped TiO₂ systems such as Yb³⁺/Nb⁵⁺,²¹ Zr⁴⁺/Nb⁵⁺,¹⁰ Zn²⁺/Nb⁵⁺,²² and Al³⁺/Nb⁵⁺.²³

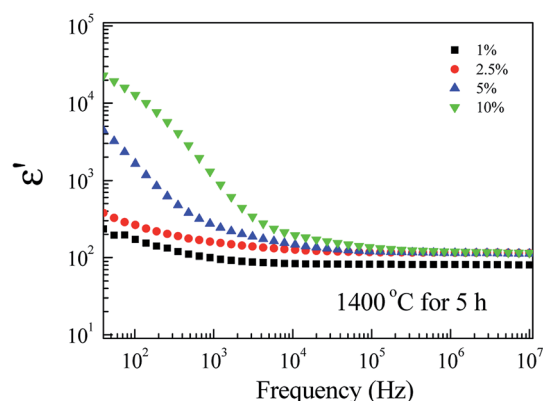


Fig. 8 Dielectric permittivity (ε') as a function of frequency of all FeNb-TO ceramics at RT.



To clarify the possible origin of the giant dielectric response in FeNb-TO ceramics, we further studied the temperature dependence of the dielectric properties at different frequencies

and temperatures. As clearly seen in Fig. 9, the giant-dielectric relaxation behavior is observed in all FeNb-TO ceramics. Typically, the step-like decrease in ϵ' and corresponding $\tan \delta$ peak

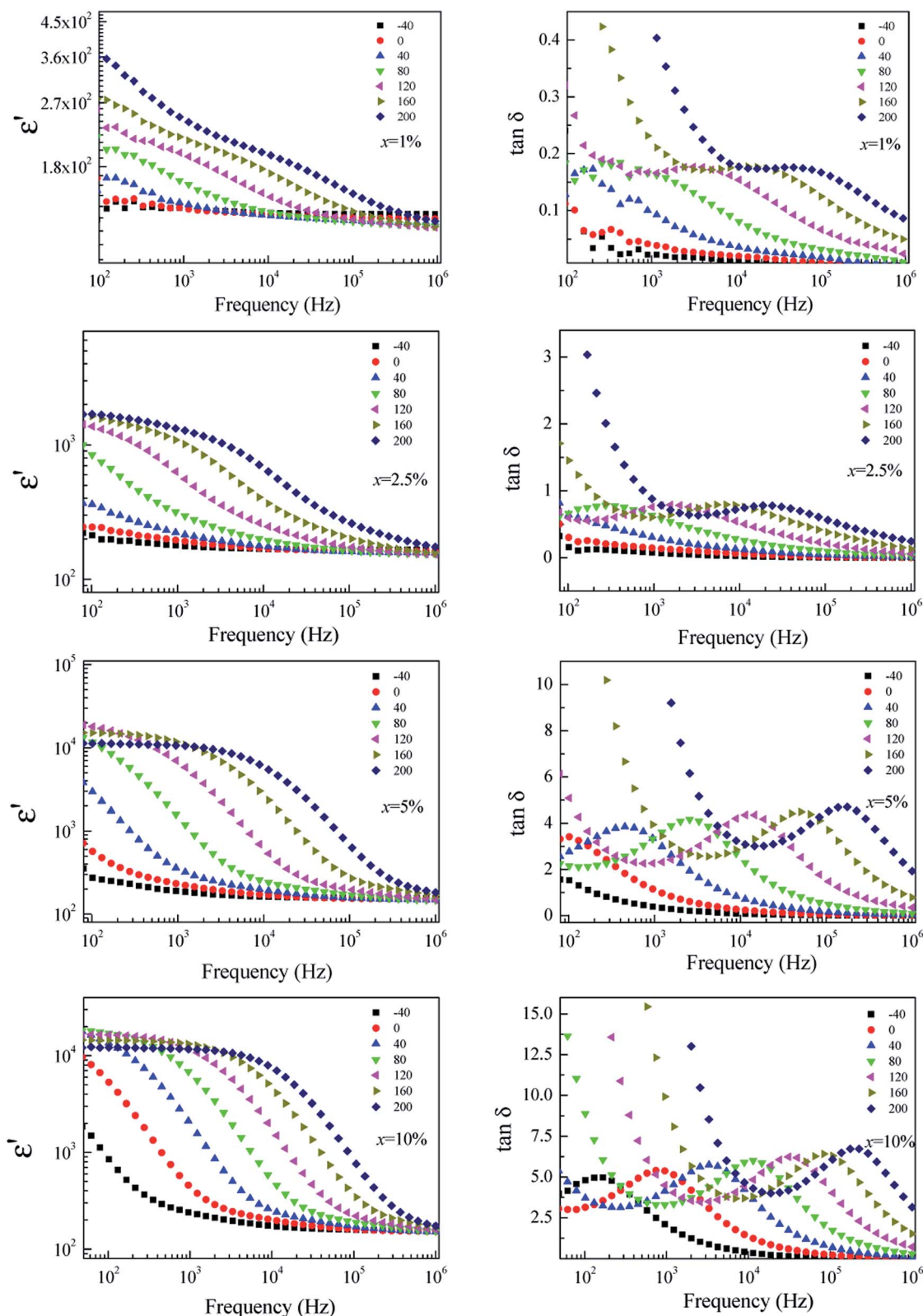


Fig. 9 Temperature dependence of the dielectric properties at different frequencies for FeNb-TO ceramics with $x = 1\%$, 2.5% , 5% , and 10% .



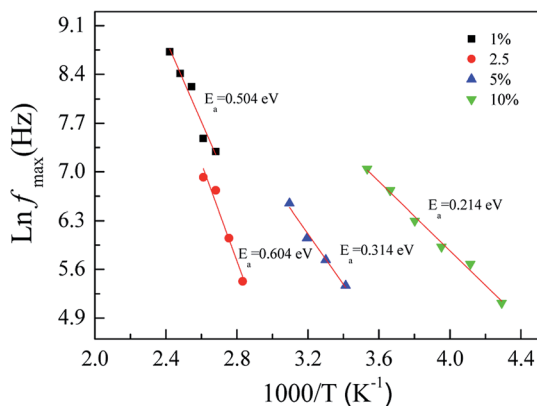


Fig. 10 Arrhenius plots of the dielectric relaxation process for all FeNb-TO ceramics.

shift to high frequencies as temperature increased. This confirmed the thermally-activated giant-dielectric relaxation behavior.³⁷ We have observed that the giant-dielectric relaxation

can be induced only in a temperature higher than RT, which would be more dominant in a high-temperature range. This dielectric behavior is not similar to those of other co-doped TiO₂ ceramics.^{3,4,7,9,11,16,18,25,38} Thus, the primary cause of the giant-dielectric relaxation should be different from those of other co-doped TiO₂ ceramics. The dielectric relaxation characteristic of the FeNb-TO ceramics is similar to that observed in the Ni_{1-x}(Li_{1/2}⁺Fe_{1/2}³⁺)_xO ceramics.³⁹

According to the observed dielectric relaxation behavior, the activation energy (E_a) for the relaxation process in the FeNb-TO ceramics can be calculated from the temperature dependence of the relaxation peak of $\tan \delta$ (f_{\max}), following the Arrhenius law. Fig. 10 displays the Arrhenius plots of all FeNb-TO ceramics. The activation energy required for the giant-dielectric relaxation in FeNb-TO ceramics was calculated from the slope of the $\ln f_{\max}$ vs. $1000/T$ plots. The E_a values of the FeNb-TO ceramics with $x = 1\%$, 2.5% , 5% , and 10% were, respectively, found to be 0.566 , 0.604 , 0.314 , and 0.214 eV. The E_a values with 0.314 and 0.214 eV are closed to the E_a values of other giant dielectric oxides that contain Fe²⁺/Fe³⁺ ions such as BiFeO₃ (0.325 eV)⁴⁰

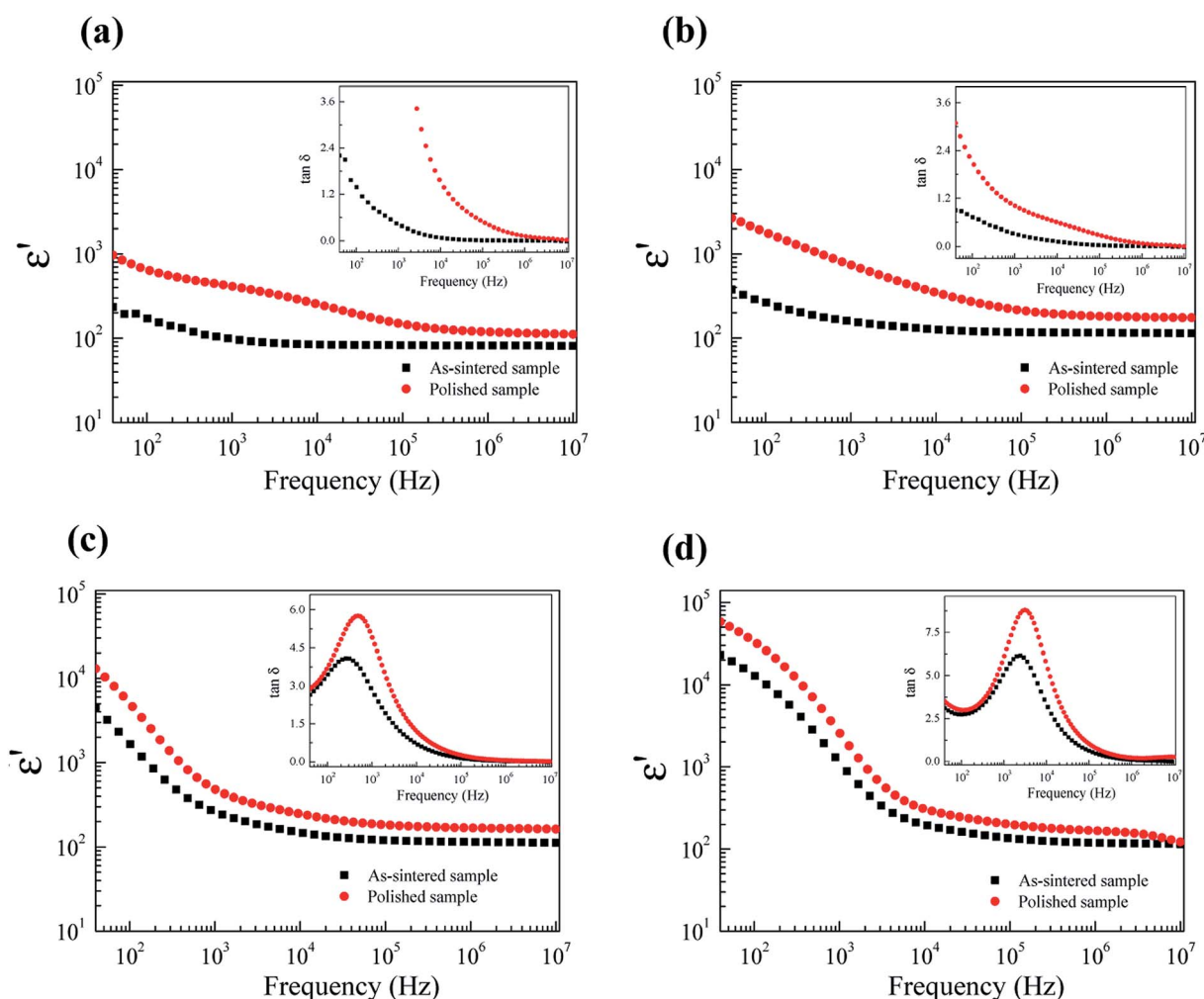


Fig. 11 Dielectric permittivity (ϵ') at RT of as-sintered and polished samples for FeNb-TO ceramics with (a) $x = 1\%$, (b) $x = 2.5\%$, (c) $x = 5\%$, and (d) $x = 10\%$; their insets show $\tan \delta$ at RT as a function of frequency.



and LuFe_2O_4 (0.3 eV).⁴¹ Furthermore, the $E_a = 0.566$ and 0.604 eV may be resulted from the second ionization of oxygen vacancies.⁴² It is important to note that the dielectric relaxation should be associated with the electron hopping between $\text{Ti}^{3+}/\text{Ti}^{4+}$ and/or $\text{Fe}^{2+}/\text{Fe}^{3+}$ ions. The $\text{Ti}^{3+}/\text{Ti}^{4+}$ ratio could be increased with increasing the Nb^{5+} doping concentration. Therefore, the hopping can easily be activated when the Ti^{3+} or Fe^{3+} ions concentration increased, giving rise to a decrease in the E_a values for the FeNb-TO ceramics with $x = 5\%$ and 10% .

To further clarify the possible origin of the giant-dielectric relaxation in FeNb-TO ceramics, the effect of the outer surface layer on the dielectric properties was investigated since it had a great effect on the giant dielectric response in $\text{Ga}^{3+}/\text{Ta}^{5+}$ (ref. 28) and $\text{In}^{3+}/\text{Nb}^{5+}$ co-doped TiO_2 oxides.¹⁴ Generally, the surface layer, which contains additional cations like Mn and Mg shows different element configurations from the core structure. This result may influence the dielectric and electrical properties of the FeNb-TO ceramics. Both sides of the outer surface with 0.5 mm in thickness (for each side) were removed by polishing. After removing the outer surface of the as-sintered samples, the dielectric properties changed significantly, especially for the dielectric properties in a low-frequency range of the FeNb-TO ceramic with $x = 1\%$ (Fig. 10). Both of the ϵ' and $\tan \delta$

increased. This indicates that the SBLC has a great effect on the overall dielectric properties of FeNb-TO ceramics. Thus, the outer surface layer is one of the most important factors contributing on the overall dielectric properties of FeNb-TO ceramics. The increase in a low-frequency $\tan \delta$ indicates the increase in conductivity. Hence, the electrical properties of the outer surface layer of the FeNb-TO ceramics, which were prepared by a chemical method, are insulator compared to the inner core. Nevertheless, the investigation on the structure of the surface layer should be performed in the future work to clarify the different element configurations between the inner core and outer surface layer. Although the exact thickness of the outer surface layer cannot be estimated in this experiment, it was clearly shown that the outer surface layer plays an important role in dielectric responses of the FeNb-TO ceramics.

According to the Raman and XPS results, the presence of oxygen vacancies in FeNb-TO ceramics may be originated by Fe^{3+} ions. Oxygen vacancies and Ti^{3+} have been proved to occur. Thus, the giant-dielectric relaxation in FeNb-TO ceramics may be originated from the EPDD. To clarify this, calculations were performed using the GGA formalism with the VASP code. Periodic boundary conditions were employed on $2 \times 2 \times 6$ super-cell of the rutile crystallographic unit cell as shown in

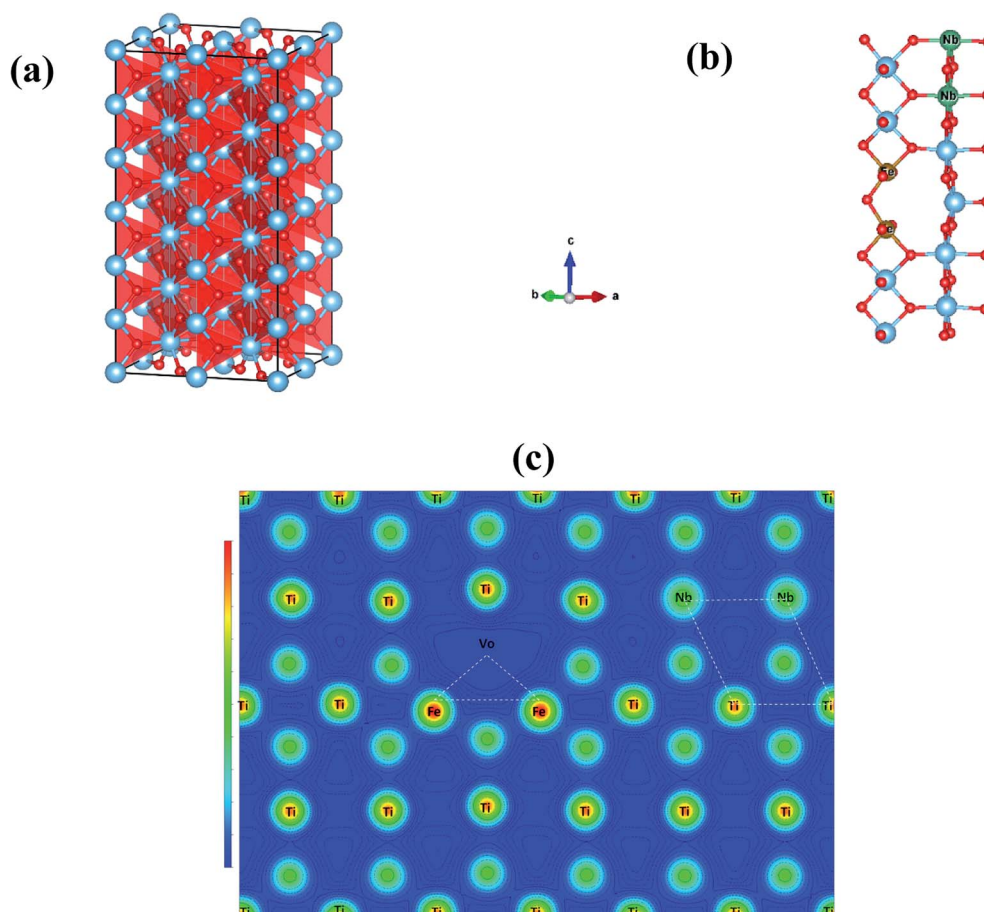


Fig. 12 (a) $2 \times 2 \times 6$ super-cell rutile- TiO_2 structure, (b) energy-preferable structure of the 2FeV_o triangular defect and 2Nb diamond, and (c) electron density of energy preferable $2\text{NbV}_o2\text{FeTiO}_2$ structure in 110 plane.



Fig. 11(a). We firstly created one oxygen vacancy and then replaced two Ti atoms with two Nb atoms and another two Ti atoms with two Fe atoms in rutile TiO_2 . This structure is defined as $2\text{NbV}_o2\text{FeTiO}_2$ (V_o stands for the oxygen vacancy). For each configuration, we allowed all atoms to relax fully. Based on our total energy calculations, we used the most stable configurations of $2\text{FeV}_o\text{TiO}_2$ and 2NbTiO_2 to further investigate the lowest energy configuration of the FeNb-TO ceramics, by placing the 2FeV_o triangular and 2Nb diamond defects into the TiO_2 structure simultaneously in 3 configurations, near opposite and far. When the 2FeV_o triangular and 2Nb diamond defects were present in TiO_2 , the stable structure of 2NbTiO_2 as shown in Fig. 11(b), we found that 2Nb atoms preferentially form a diamond-shaped structure. On the basis of total energy, we found that the 2FeV_o triangular defect does not prefer to be close to the 2Nb diamond defect, as shown in Fig. 11(c) revealed that the case resulted in the lowest total energy. This result indicates that there is a small coupling between the 2FeV_o triangular and 2Nb diamond defects (Fig. 12).

According to the experimental and theoretical investigations, it can be clearly suggested that the giant-dielectric relaxation behavior of FeNb-TO ceramics was not originated from both of the EPDD and IBLC models. Although the SBLC has an effect on the dielectric properties, it was not the primary cause for the observed giant dielectric relaxation in FeNb-TO ceramics. Instead, the electron hopping mechanism between $\text{Ti}^{3+} \leftrightarrow \text{Ti}^{4+}$ ions was suggested to the most possible mechanism related to the giant-dielectric relaxation in FeNb-TO ceramics.

4. Conclusions

In the experimental investigation, FeNb-TO powders with pure rutile- TiO_2 phase were successfully synthesized by a combustion process. The microstructure of all the sintered ceramics with homogeneous dispersion of dopants was highly dense microstructure without porosity. The presence of oxygen vacancies was confirmed by Raman and XPS techniques. The FeNb-TO ceramics exhibited the thermally activated giant-dielectric relaxation above RT. It was clearly shown that the outer surface layer had a little influence on giant-dielectric relaxation. Obviously, both the IBLC and SBLC effects cannot be used to clearly explain the dielectric behavior of FeNb-TO ceramics. In the theoretical investigation, we also used the density functional theory (DFT) to calculate the ground state structure to know the origin of colossal dielectric properties in the FeNb-TO ceramic by replacing four atoms Ti with two atoms of Fe and two atoms of Nb. An oxygen vacancy was introduced into the system. The calculation results showed that, in the energy preferable configuration, the 2Fe atoms are located near the oxygen vacancy and far away from the 2Nb atoms. These structures can form $2\text{Nb}2\text{Ti}$ diamond shape and FeV_oTi triangle shape. Thus, the electron-pinned defect-dipoles cannot be formed in the FeNb-TO structure. Finally, we can suggest that the giant-dielectric relaxation behavior of FeNb-TO ceramics was not originated from both of the EPDD and IBLC/SBLC. The electron hopping mechanism was suggested to the most

possible mechanism related to the giant-dielectric relaxation in FeNb-TO ceramics.

Conflicts of interest

There is no conflicts to declare.

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